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## Structural, electronic and thermoelectric properties of boron phosphorous nitride $B_2PN$ via first principles study

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A theoretical study of monolayer boron phosphorous nitride ( $B_2PN$ ) is performed to explore its electronic and thermoelectric properties. The thermodynamic stability is determined by the formation energy of a monolayer. The dynamic stability is obtained from the phonon dispersion curve. We performed an AMID simulation to ensure the thermal stability and found that our material is thermally stable at 700 K. The system possesses direct band gaps of 0.25 eV and 0.4 eV with Perdew–Burke–Ernzerhof (PBE) and hybrid functional (HSE), respectively. The Seebeck coefficient is found to be the same in both directions, and the maximum value is 1.55  $\mu\text{V K}^{-1}$ . The relaxation time is found to be longer for the hole-doped system than the electron-doped system. It is observed that electrical conductivity is greater for hole-doped system in both directions, and a similar trend is observed for electronic thermal conductivity. We found that the lattice thermal conductivity of our systems is anisotropic. The lattice thermal conductivity along the  $Y$ -direction is greater than that in the  $X$ -direction. The calculation performed for the figure of merit ( $ZT$ ) reveals that the system has a high  $ZT$  of 1.14 for a hole-doped system. The figure of merit makes the system a promising candidate for potential thermoelectric device applications.

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## Introduction

Thermoelectric materials are of great importance due to the increase in energy consumption. These materials are advantageous because they help to reduce global warming by converting heat into electrical power.<sup>1</sup> The conversion of thermoelectricity by the Seebeck effect is calculated using the formula  $\Delta V = S\Delta T$ , where  $S$  (Seebeck coefficient) is the thermoelectric power based on the voltage difference ( $\Delta V$ ) instead of the polarization of the electric potential.<sup>2</sup> The figure of merit ( $ZT$ ) indicates how efficient the material is for thermoelectric applications.<sup>3</sup> Additional characteristics are also monitored for the selection of the thermoelectric materials, such as the lattice thermal conductivity, relaxation time and group velocity.

To make a real device, numerous techniques have been applied and attempted to obtain efficient materials with a high figure of merit. To this end, many bulk materials have been studied. For instance, well-known bulk-type  $\text{Bi}_2\text{Te}_3$  and  $\text{PbTe}$  thermoelectric candidates exhibit very high  $ZT$  at high temperatures.<sup>3–7</sup> Their  $ZT$  is found in the range of 1–2. However, the preservation of  $ZT$  under very limited conditions limits their use.

In addition to bulk materials, two-dimensional (2D) materials are also being explored owing to their potential as efficient thermoelectric materials. For instance, in 2D carbon materials,

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multiple topological structures are either predicted theoretically or synthesized empirically. These structures include pentagraphene, carbon eneyne,<sup>8</sup> biphenylene,<sup>9</sup>  $\gamma$ -graphyne,<sup>10</sup> and various graphynes.<sup>11,12</sup> In addition to adding new characteristics, doping with hetero atoms in carbon allotropes, most frequently nitrogen or boron atoms, can also result in the production of novel 2D systems, such as g-C<sub>3</sub>N<sub>4</sub> and T-C<sub>3</sub>N.<sup>13,14</sup> BN is a common dipole dopant used in 2D carbon systems. It is a synthetic III-V chemical compound with equal numbers of boron (B) and nitrogen (N) atoms.<sup>15,16</sup> Within the lattice, B and N are covalently bonded, whereas the van der Waals force weakly binds the layers together. Out of the four prevalent phases, which are cubic (c-BN), wurtzite (w-BN), rhombohedral (r-BN), and hexagonal (h-BN), the most stable phase of boron nitride at room temperature is believed to be h-BN.<sup>17</sup> Remarkably, the band gap in the graphyne-like BN monolayer structures may be partially modified by varying the B-N chain length.<sup>18</sup> Niazian was able to assess the thermoelectric features through the use of a BN nanosheet structure simulation and figure of merit (ZT) calculations at 200, 300, and 600 K temperatures. At 200, 300, and 600 K, the ZT values of the BN nanosheet structure were 0.97, 1.03, and 1.70, respectively, indicating the strong thermoelectric performance of the nanosheets at high temperatures. The thermoelectric characteristics of a defective boron nitride (BN) nanosheet were also examined in this study, and it was shown that the ZT value of the defect-free BN nanosheet was much higher than the ZT value of a BN nanosheet with a single vacancy defect.<sup>19</sup> Improving the thermoelectric appropriateness of materials is fairly challenging because all the internal parameters are intimately linked. However, the high performance of these materials may result in various applications in the future. This study presents the thermoelectric properties of 2D B<sub>2</sub>PN, driven by the potential applications of boron nitride (BN) systems highlighted in contemporary research. This study reveals that these materials are promising for thermoelectric applications. It is anticipated that this effort will enable researchers to explore this area more thoroughly and address future challenges.

## Computational techniques

Herein, the structural, electronic and thermoelectric properties of monolayer B<sub>2</sub>PN are investigated using the Vienna *Ab initio* Simulation Package (VASP). The structure is fully relaxed with PBE potentials until the force becomes 0.001 eV Å<sup>-1</sup>. The energy criteria of 10<sup>-6</sup> are set up for the entire calculation. The K-mesh of 11 × 11 × 1 is considered to obtain an accurate result. A Z-direction vacuum of 20 Å is created to prevent periodic interaction. After full relaxation of the structure, the band structure is computed with PBE and HSE potentials. The PHONOPY code is used to calculate the phonon dispersion curve. For the phonon dispersion curve, the supercell of 9 × 9 × 1 is taken with K-point 6 × 6 × 1. Using the BoltzTrap2 code, the thermoelectric features, such as the Seebeck coefficient, thermal conductivity and electrical conductivity, are computed. The thermoelectric features, such as electrical conductivity and electronic thermal conductivity, obtained from the BoltzTrap2

code, depend on the relaxation time. To make these features independent of the relaxation time, we calculated the relaxation time. For temperature and energy-dependent relaxation time calculation, we included the acoustic phonon scattering, ionized impurity scattering effects and optical phonon. The phono3py code is used to calculate the lattice thermal conductivity. For lattice thermal conductivity, the supercell of 3 × 3 × 1 is used. The energy criteria of 10<sup>-8</sup>, cutoff energy 550 eV and K-mesh of 2 × 2 × 1 are taken. In addition to these, a q-mesh of 90 × 70 × 1 is taken for accurate results.

## Results and discussion

The top and side views of the B<sub>2</sub>NP monolayer structure are shown in Fig. 1(a) and (b). The orange, purple, and green spheres represent phosphorous, nitrogen, and boron, respectively. With lattice constants of  $a = 5.12$  Å and  $b = 2.79$  Å, the monolayer possesses an orthorhombic structure exhibiting *Pmmm*-47 symmetry. To verify thermodynamic stability, the monolayer formation energy ( $E_F$ ) is computed using the following relation:<sup>20</sup>

$$E_F = E_{\text{di-BPN}} - (2 E_B + E_N + E_N), \quad (1)$$

where boron, phosphorous and nitrogen total energies are denoted by  $E_B$ ,  $E_P$  and  $E_N$ , respectively. Table 1 shows the formation energy for the system. Monolayer B<sub>2</sub>PN thermodynamic stability is confirmed by its negative formation energy value.<sup>21</sup> Furthermore, we investigate the thermal stability using the *ab initio* molecular dynamic (AMID) simulations at 700 K. For MD simulations, we consider a 2 × 2 × 1 supercell to minimize the constraint of periodic boundary conditions. Fig. 1(c) shows the evolution of potential energy (eV) for the B<sub>2</sub>PN monolayer systems. The inset displays a snapshot of the atomic structure at five picoseconds (ps) at 700 K using the canonical (NVT) ensembles. The structural integrity is preserved even after 5 ps although some slight distortions can be observed in the structure, but the bonds between atoms are still present. This suggests that the B<sub>2</sub>PN monolayer systems are thermally stable at 700 K. To ensure dynamic stability, we calculated the phonon dispersion curve. The obtained phonon dispersion curves are presented in Fig. 2. There is no imaginary peak present in the dispersion curve, indicating the dynamic stability of the system. The band structures with PBE and HSE along a high symmetric path are calculated, as shown in Fig. 3(a) and (b). Direct band gaps of 0.25 eV and 0.4 eV were found for the B<sub>2</sub>NP with PBE and HSE.

First, we explain the relationship between carrier concentration and chemical potential. Carrier concentration refers to the number of charge carriers (electrons or holes) per unit volume in a material, and it plays a crucial role in determining the electrical conductivity, Seebeck effect and thermal conductivity of thermoelectric materials. Doping introduces impurity states within the band gap, significantly altering the carrier concentration. N-type doping adds electrons, shifting the Fermi level closer to the conduction band and increasing the electron concentration. Conversely, p-type doping introduces holes,



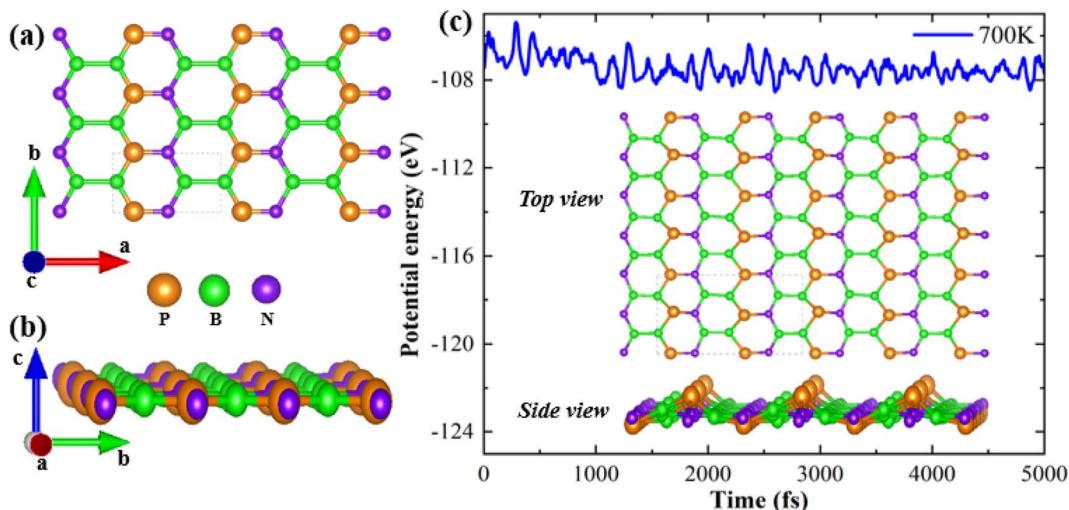


Fig. 1 (a) Top view and (b) side view of the optimized crystal structure of B<sub>2</sub>PN, and (c) evolution of potential energy with a simulation time for B<sub>2</sub>PN. The inset shows the top and side views of the structure with molecular dynamics at 700 K.

Table 1 The obtained lattice constant and formation energy of the monolayer

Structure	Lattice constant Å	Formation energy eV per atom
Monolayer	$a = 5.12 \text{ \AA}$ , $b = 2.79 \text{ \AA}$	-5.58

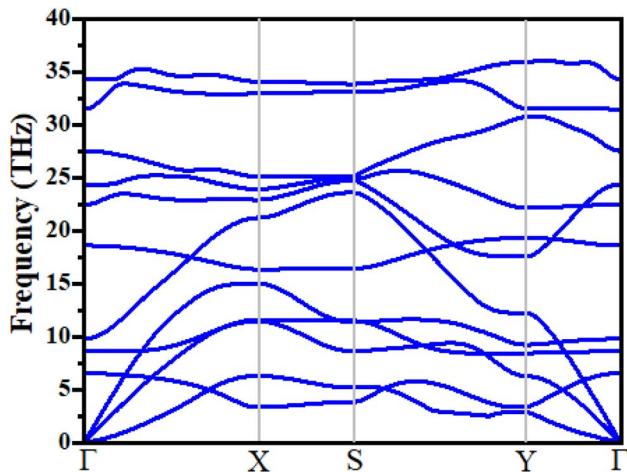


Fig. 2 Phonon spectrum of B<sub>2</sub>NP monolayer systems.

shifting the Fermi level closer to the valence band and increasing the hole concentration. Understanding the relationship between the carrier concentration and energy is essential for designing materials with enhanced thermoelectric efficiency. Fig. 4 illustrates the relationship between chemical potential and carrier concentration. Positive values of chemical potential correspond to n-type carriers, indicating an excess of electrons, while negative values signify p-type carriers, reflecting the abundance of holes.

Now, we present an important thermoelectric parameter known as the Seebeck coefficient. The relationship shown below can be used to obtain the Seebeck coefficient.<sup>22</sup>

$$S(T, \mu) = \frac{1}{eT} \left( \frac{\int \sigma_{z\beta}(\varepsilon)(\varepsilon - \mu) \left[ -\frac{\partial f_\mu(T; \varepsilon)}{\partial \varepsilon} \right] d\varepsilon}{\int \sigma_{z\beta}(\varepsilon) \left[ -\frac{\partial f_\mu(T; \varepsilon)}{\partial \varepsilon} \right] d\varepsilon} \right), \quad (2)$$

where the electron charge, conductivity tensor at a given electron energy ( $\varepsilon$ ), and temperature are represented by  $e$ ,  $\sigma_{z\beta}(\varepsilon)$ , and  $T$ , respectively. The chemical potential and Fermi-Dirac distribution function are represented by  $\mu$  and  $f_\mu$ .<sup>23</sup>

The temperature-dependent Seebeck coefficient as a function of chemical potential is illustrated in Fig. 5(a) and (b). Charge carrier type dominance is shown by the sign of the Seebeck coefficient. As can be observed in the figure, the Seebeck coefficient in monolayer B<sub>2</sub>NP systems did not behave anisotropically because it exhibited almost the same trend in both the X- and Y-directions. In both hole- and electron-doped systems, the X- and Y-direction have almost the same Seebeck coefficient. For example, the maximum Seebeck coefficient in the X-direction at a chemical potential of 0.05 eV is 1.55 mV K<sup>-1</sup>, while in the Y-direction at 300 K, it is 1.55 mV K<sup>-1</sup> at the same chemical potential. Additionally, the Seebeck coefficient decreases as the temperature increases.

Now, we present the relaxation time with respect to the chemical potential. However, it is worth noting that the relaxation time  $\tau$  is in principle dependent on both temperature ( $T$ ) and energy ( $E$ ). This may greatly affect the electrical conductivity and electronic thermal conductivity. Therefore, we adopted the analytic formula to calculate the energy and temperature relaxation times.<sup>24</sup> Here, the total relaxation time ( $\tau_{\text{tot}}$ ) is defined as follows:

$$\frac{1}{\tau_{\text{tot}}(T, E)} = P_{\text{imp}} + P_{\text{ac}} + P_{\text{polar}}, \quad (3)$$



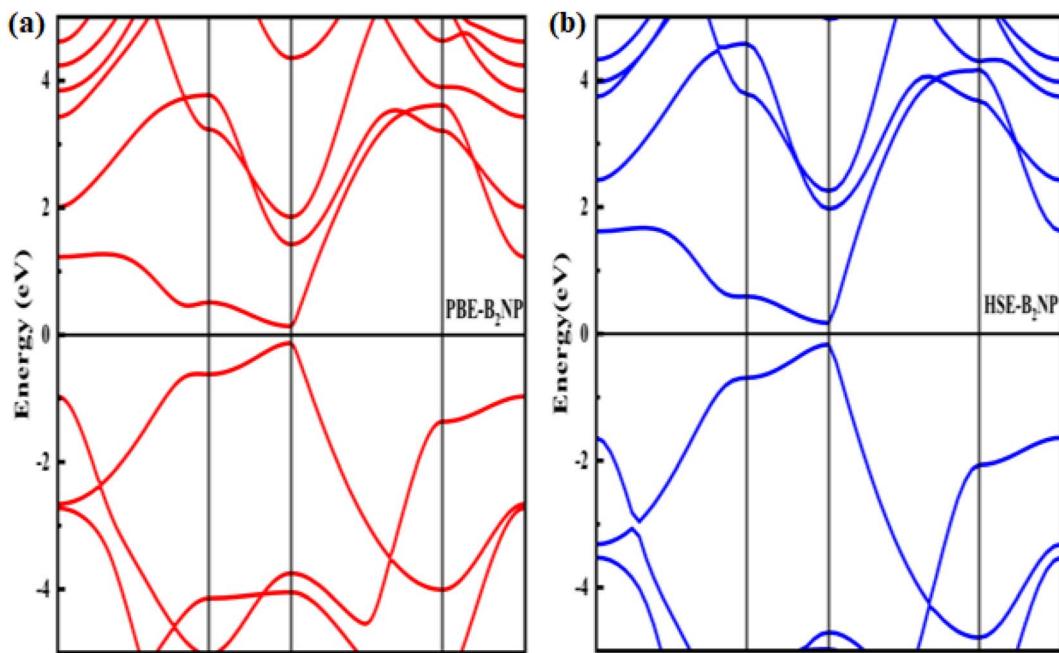


Fig. 3 Electronic band structures of (a) PBE-B<sub>2</sub>NP and (b) HSE-B<sub>2</sub>NP monolayer systems.

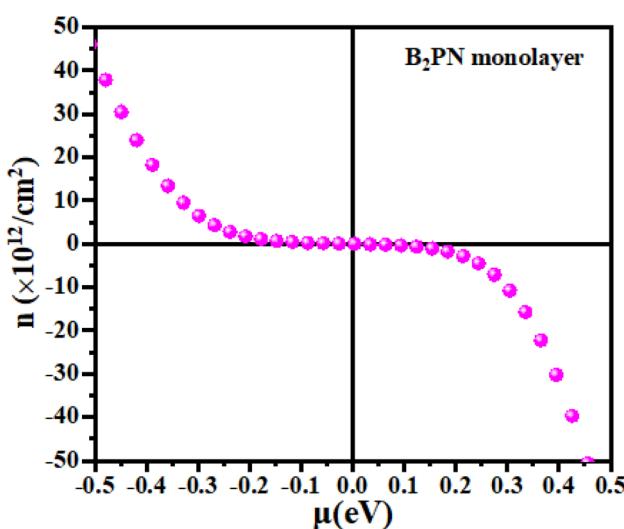


Fig. 4 The calculated carrier concentration as a function of the chemical potential of the B<sub>2</sub>NP monolayer system.

where the impurity scattering rate ( $P_{\text{imp}}$ ) was adopted from the Brooks-Herring formula

$$P_{\text{imp}}(T, E) = \frac{\pi n_{\text{i}} Z_{\text{i}}^2 e^4 E^{-3/2}}{\sqrt{2\bar{m}} (4\pi\epsilon_0\epsilon_s)^2} \left[ \log\left(1 + \frac{1}{x}\right) - \frac{1}{1+x} \right]. \quad (4)$$

here,  $n_{\text{i}}$ ,  $Z_{\text{i}}$ ,  $\epsilon_0$ ,  $\epsilon_s$ , and  $\bar{m}$  represent the ionized impurity concentration, impurity charge, vacuum permittivity, relative dielectric constant, and average effective mass, respectively.

Note that  $q_0$  is the Debye screening wavevector and  $x = \frac{\hbar^2 q_0^2}{8\bar{m}E}$ . Acoustic phonon scattering ( $P_{\text{ac}}$ ) is treated within the

deformation potential approach in a long wavelength acoustic phonon limit:

$$P_{\text{ac}}(T, E) = \frac{(2\bar{m})^{3/2} k_{\text{B}} T D^2 \sqrt{E}}{2\pi\hbar^4 \rho v^2}, \quad (5)$$

where  $E$  and  $D$  are the electron energy and deformation potential of the band energies calculated at the band extrema, respectively, while  $\rho$  and  $v$  are the mass density and average sound velocity, respectively. Optical polar scattering ( $P_{\text{polar}}$ ) is defined using the Ridley model:<sup>24</sup>

$$P_{\text{polar}}(T, E) = \sum_i \frac{C(T, E, e_{\text{i}}^{\text{LO}}) - A(T, E, e_{\text{i}}^{\text{LO}}) - B(T, E, e_{\text{i}}^{\text{LO}})}{Z(T, E, e_{\text{i}}^{\text{LO}}) E^{3/2}}, \quad (6)$$

where the sum is overall longitudinal-optical phonons with energy  $e_{\text{i}}^{\text{LO}}$ . More details about functions  $A$ ,  $B$ ,  $C$ , and  $Z$  can be found elsewhere.<sup>25</sup> The phenomenological parameters required in this expression were calculated using the first principle calculations. The effect of scattering can be estimated from the intrinsic parameters of the material, such as the dominant LO-phonon frequency ( $\hbar\omega_{\text{LO}}$ ), deformation potential ( $D$ ), effective mass ( $m^*$ ), lattice ( $\epsilon_{\text{L}}$ ) dielectric constants, average sound velocity ( $v$ ), high-frequency ( $\epsilon_{\infty}$ ), and density of material ( $\rho$ ). Table 2 illustrates all the parameters for the monolayer system in the  $X$ - and  $Y$ -direction. We computed the relaxation time for the monolayer system in the  $X$ - and  $Y$ -direction using these variables. The obtained results are presented in Fig. 6(a) and (b). In both hole- and electron-doped systems, the relaxation time in the  $Y$ -direction is longer than that in the  $X$ -direction. Furthermore, for the monolayer system in both directions, the hole-doped system has a longer relaxation time than the electron-doped system because of its effective mass. Additionally, it is observed that the relaxation time becomes shorter as the doping

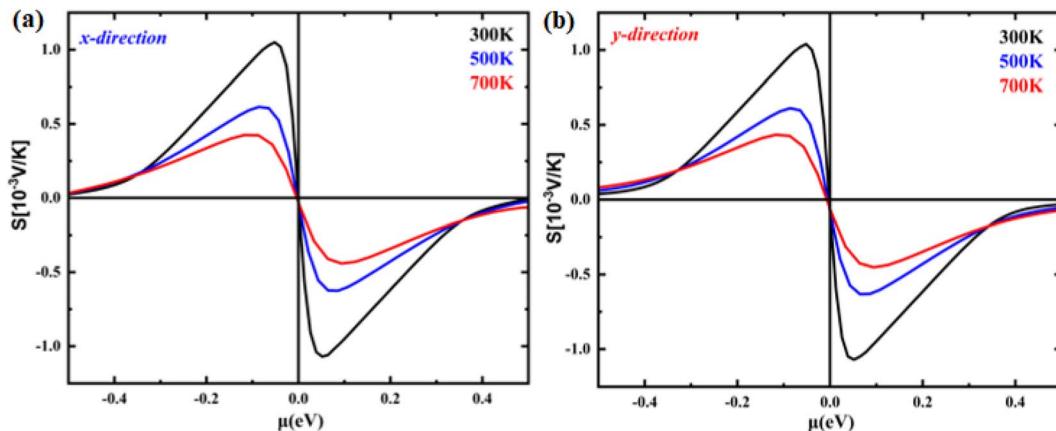


Fig. 5 The calculated Seebeck coefficient as a function of chemical potential at 300 K, 500 K and 700 K temperatures of (a)  $\text{B}_2\text{NP}$  monolayer in the  $X$ -direction and (b)  $\text{B}_2\text{NP}$  monolayer in the  $Y$ -direction.

Table 2 Calculated effective mass ratio ( $m^*/m$ ), DP constant ( $D$ ), high-frequency ( $\varepsilon_\infty$ ) and lattice ( $\varepsilon_L$ ) dielectric constants, average sound velocity ( $v$ ), the dominant LO-phonon frequency ( $\hbar\omega_{\text{LO}}$ ), and the density of material ( $\rho$ ) of  $\text{B}_2\text{PN}$  monolayer system

System	Direction	Carrier type	$m^*/m$	$D$ (eV)	$\varepsilon_\infty$	$\varepsilon_L$	$v$ ( $\text{m s}^{-1}$ )	$\hbar\omega_{\text{LO}}$ (meV)	$\rho$ ( $\text{kg m}^{-3}$ )
$\text{B}_2\text{PN}$ monolayer	$X$	e	1.1	4.2	2.9	4.93	9579	141	4412
		h	0.7	4.0	2.9	4.93	9579	141	4412
	$YY$	e	1.3	3.8	3.2	4.95	11 605	141	4412
		h	0.2	3.5	3.2	4.95	11 605	141	4412

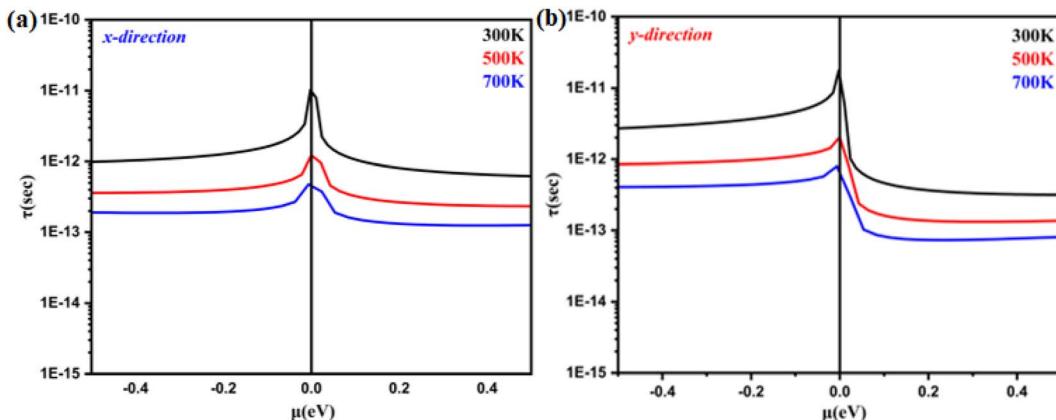


Fig. 6 Relaxation time as a function of the chemical potential of monolayer systems at 300 K, 500 K and 700 K in (a) the  $X$ -direction and (b)  $Y$ -direction.

concentration increases. This occurs because doping introduces more free charges (holes or electrons) into the materials, which leads to increased scattering events among charge carriers. Consequently, the average time between collisions, known as the relaxation time, decreases with higher doping concentrations. This increased scattering reduces the mobility of the charge carriers, impacting the overall electrical and thermal properties of the materials.

Now, in Fig. 7(a) and (b), we compute the electrical conductivity using the Boltzmann method, which is incorporated into the Boltztrap2 code and may be written as follows:

$$\sigma(T; \mu) = e^2 \int \sigma_{\alpha\beta}(\varepsilon) \left[ -\frac{\partial f_\mu(T, \varepsilon)}{\partial \varepsilon} \right] d\varepsilon, \quad (7)$$

$$\sigma_{\alpha\beta}(\varepsilon, T) = \int \sum_b v_{b \times k} v_{b,k} \tau_{b,k} \delta(\varepsilon - \varepsilon_{b,k}) \frac{dk}{8\pi^3}, \quad (8)$$

where the conductivity tensor is denoted by  $\sigma_{\alpha\beta}(\varepsilon)$ , while  $f_\mu$  and  $e$  represent the Fermi distribution function and electron charge, respectively. The group velocity, cartesian indices, and carrier-dependent relaxation time are denoted by variables  $v_b$ ,  $k$ , and



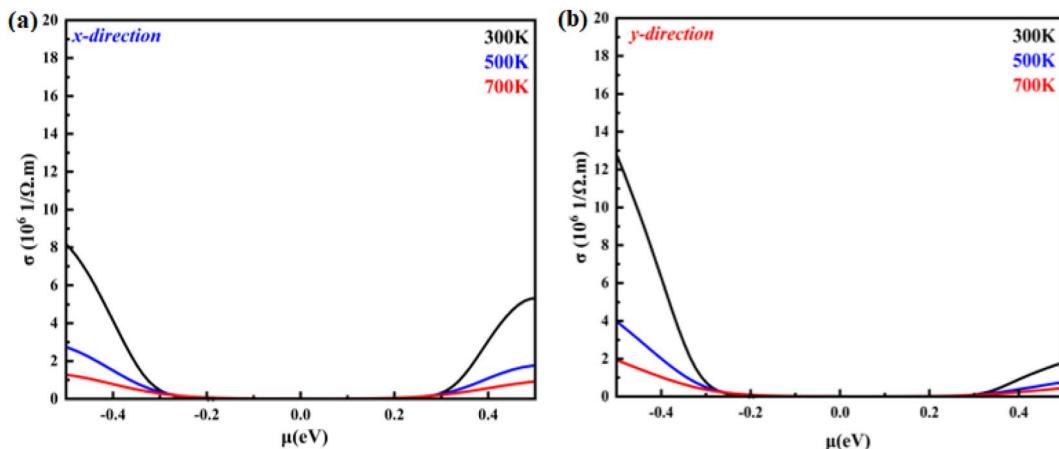


Fig. 7 Electrical conductivity as a function of the chemical potential of monolayer systems at 300 K, 500 K and 700 K in (a) the *X*-direction and (b) *Y*-direction.

$\tau_b$ ,  $k$ , respectively. Note that the electrical conductivity ( $\sigma(\tau)$ ) depends on the relaxation time.

Fig. 8(a) and (b) shows the temperature-dependent electrical conductivity of the monolayer system in the *X*- and *Y*-direction. The electrical conductivity of the hole-doped system is greater than that of the electron-doped system in the *X*- and *Y*-direction. This feature is attributed to the relaxation time. For the hole-doped system, its relaxation time is longer in the *X*- and *Y*-direction than that of the electron-doped system. For instance, the electrical conductivity in the *X*-direction for the hole-doped system is found to be  $8 \times 10^6 (\Omega^{-1} \text{ m}^{-1})$  with chemical potential values of 0.5 eV at 300 K, while in the *Y*-direction at the same temperature and same system, it is found to be  $12.7 \times 10^6 (\Omega^{-1} \text{ m}^{-1})$ . It is observed that the electrical conductivity of the monolayer B<sub>2</sub>NP system is isotropic in both directions and developed nonlinearly with the chemical potential. Overall, the electrical conductivity in the *Y*-direction is greater than that in the *X*-direction.

A material's thermal conductivity can be determined by measuring the heat conduction resulting from charge carrier

movement and lattice vibration. The sum of the lattice thermal conductivity ( $\kappa_L$ ) and electronic thermal conductivity ( $\kappa_e$ ) can be used to express the total thermal conductivity ( $\kappa$ ). The electronic thermal conductivity can be stated using the Boltzmann transport theory as follows:

$$\kappa_e(T, \mu) = \frac{1}{e^2 T} \left( \int \sigma_{\alpha\beta}(\varepsilon) (\varepsilon - \mu)^2 \left[ -\frac{\partial f_\mu(T; \varepsilon)}{\partial \varepsilon} \right] d\varepsilon \right), \quad (9)$$

where  $\mu$  is the chemical potential,  $\sigma_{\alpha\beta}(\varepsilon)$  is the conductivity tensor,  $e$  is the elementary charge,  $T$  is temperature,  $\varepsilon$  is the electron energy state and  $f_\mu$  is the Fermi-Dirac distribution function. The electronic thermal conductivity of a monolayer system at temperatures of 300, 500, and 700 K is shown in the *X*- and *Y*-direction in Fig. 8(a) and (b). We found that the B<sub>2</sub>NP exhibited an isotropic behavior. The hole-doped system has higher electronic thermal conductivity than the electron-doped system in both directions. This is attributed to the relaxation time. It is further found that heat conductivity is greater in the *Y*-direction than in the *X*-direction. Conversely, lattice thermal conductivity can be written as follows:

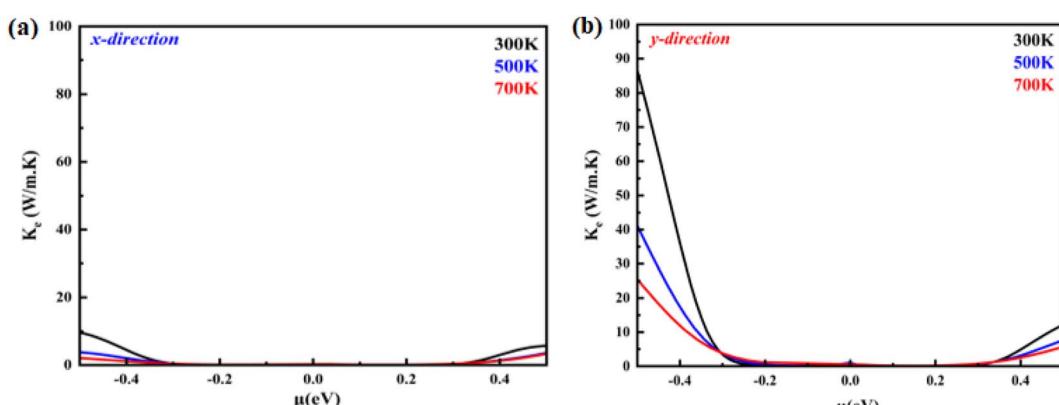


Fig. 8 Electronic thermal conductivity as a function of the chemical potential of monolayer systems at 300 K, 500 K and 700 K in (a) the *X*-direction and (b) *Y*-direction.



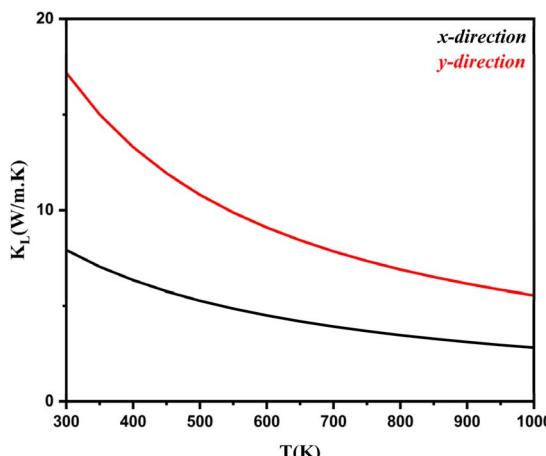


Fig. 9 Lattice thermal conductivity as a function of the chemical potential of monolayer systems at 300–1000 K in the *X*- and *Y*-direction.

$$\kappa_L = \frac{1}{NV} \sum_{\lambda} K_{\lambda} = \frac{1}{NV} \sum_{\lambda} C_{\lambda} v_{\lambda}^2 \tau_{\lambda} . \quad (10)$$

In this case,  $V$  and  $N$  denote the system's volume and unit cell. The phonon group velocity, phonon lifespan, and mode heat capacity are represented by  $v_{\lambda}$ ,  $\tau_{\lambda}$ , and  $C_{\lambda}$ , respectively. The mode heat capacity is  $\tau_{\lambda} = 1/2\Gamma_{\lambda}(\omega_{\lambda})$ , where  $\Gamma$  can be written as

$$\Gamma = \frac{18\pi}{\hbar^2} \sum_{\lambda' \lambda''} \Delta(-q + q' + q'') N_{\lambda' \lambda''}(\omega) |\Phi_{-\lambda \lambda' \lambda''}|^2 .$$

Here,  $\Phi_{-\lambda \lambda' \lambda''}$  is the phonon–phonon interaction strength among the three phonons  $\lambda$ ,  $\lambda'$ , and  $\lambda''$ . It can be computed from the second- and third-order force constants, while  $N_{\lambda' \lambda''}(\omega) = (n_{\lambda'} + n_{\lambda''} + 1)\delta(\omega - \omega_{\lambda'} - \omega_{\lambda''}) + (n_{\lambda'} - n_{\lambda''}) \times [\delta(\omega + \omega_{\lambda'} - \omega_{\lambda''}) - \delta(\omega - \omega_{\lambda'} + \omega_{\lambda''})]$ , where  $n_{\lambda} = \left[ \exp\left(\frac{\hbar\omega_{\lambda}}{k_B T}\right) - 1 \right]^{-1}$ . Fig. 9 shows the lattice thermal conductivity of a monolayer system. The lattice thermal conductivity in the *Y*-direction is higher than that in the *X*-

direction. For instance, at 300 K, the  $K_L$  in the *X*-direction is found to be  $8 (\text{W m}^{-1} \text{K}^{-1})$ , while it is  $17 (\text{W m}^{-1} \text{K}^{-1})$  in the *Y*-direction at the same temperature. Furthermore, it can be observed that as the temperature increases, the  $K_L$  decreases. This behavior occurs because phonon–phonon scattering becomes more frequent at higher temperatures. Phonons, which are the main heat carriers in semiconductor solids, scatter more often as the temperature increases, leading to a reduction in the mean free path. Consequently, the lattice thermal conductivity decreases.<sup>26</sup> Besides, we observed the anisotropic nature of lattice thermal conductivity. From the phonon dispersion curve, it can be observed that the propagation length of the acoustic modes in the  $\Gamma$ -*X*-direction is not the same as that of the  $\Gamma$ -*Y*-direction, indicating that its anisotropic nature is attributed to the crystal structure. From this behavior, we observe the anisotropic nature of lattice thermal conductivity in the *X*- and *Y*-direction.<sup>27</sup>

Using all of the previously mentioned parameters, we determine the merit figure ( $ZT$ ). The computed  $ZT$  values for the monolayer system in the *X*- and *Y*-direction are displayed in Fig. 10(a) and (b). The  $ZT$  values in both directions are greater for the hole-doped system than for the electron-doped system. This suggests that hole doping is more successful than electron doping. In addition, the  $ZT$  value is greater in the *Y*-direction than in the *X*-direction. For example, at 700 K, for p-type carriers, the value of  $ZT$  is 1.14, while in the *X*-direction, for p-type carriers, it becomes 0.4 at the same temperature. The maximum  $ZT$  is found at a carrier concentration of  $4.5 \times 10^{12} (\text{cm}^{-2})$  in the *Y*-direction, while in the *X*-direction, the maximum  $ZT$  is obtained at a carrier concentration of  $9.4 \times 10^{12} (\text{cm}^{-2})$ . Furthermore, the obtained value of  $ZT$  is higher than the reported values for 2D hexagonal beryllium telluride (0.9 at 700 K) and  $\text{Bi}_2\text{Te}_3$  (0.4).<sup>28,29</sup> The obtained value is also greater from the reported  $\text{Rb}_2\text{NaTIZ}_6$  ( $Z = \text{Cl}, \text{Br}$  and  $\text{I}$ ) bulk material.<sup>30</sup> Our results are in good agreement with previously studied thermoelectric materials, indicating their potential as promising candidates for further research.

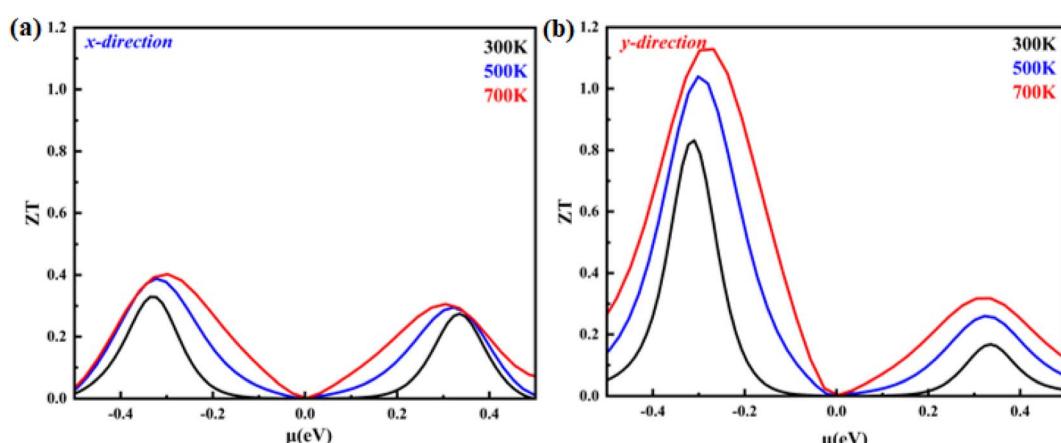


Fig. 10 Figure of merit ( $ZT$ ) as a function of the chemical potential of monolayer systems at 300 K, 500 K and 700 K in (a) the *X*-direction and (b) *Y*-direction.



## Conclusion

In this work, we investigated the electronic and thermoelectric properties of monolayer boron phosphorous nitride. The phonon dispersion curve indicates that these are dynamically stable. We performed an AMID simulation to ensure thermal stability and found that our material is thermally stable at 700 K. It was found that the band gap for the monolayer is 0.4 eV, indicating the semiconducting nature of the system. It is observed that the relaxation time is longer for the hole-doped system than for the electron-doped system. Besides, we investigated the Seebeck coefficient ( $S$ ), electrical conductivity ( $\sigma$ ), lattice thermal conductivity ( $\kappa_L$ ), electronic thermal conductivity ( $\kappa_e$ ) and figure of merit ( $ZT$ ). The Seebeck coefficient has the same maximum value of  $1.55 \text{ mV K}^{-1}$  in both directions. The electrical conductivity is found to be greater for the hole-doped system than for the electron-doped system and is greater in the  $Y$ -direction than in the  $X$ -direction. The same trend is observed for electronic thermal conductivity. The lattice thermal conductivity has values of  $8 (\text{W m}^{-1} \text{ K}^{-1})$  and  $17 (\text{W m}^{-1} \text{ K}^{-1})$  in the  $X$  and  $Y$ -direction at 300 K, respectively. The figure of merit  $ZT$  is found to be greater in the  $Y$ -direction for the hole-doped system, and its value is 1.14, while in the  $X$ -direction, its value is 0.4 at 700 K. The results of the thermoelectric investigation indicate that these can be the best applicants for thermoelectric applications.

## Data availability

The data will be made available on reasonable request.

## Conflicts of interest

The authors declare no conflicting of interest.

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